

TRANSMITTAL OF INFORMATION DISCLOSURE STATEMENT
(Under 37 CFR 1.97(b) or 1.97(c))

Docket No.
NL-010357

In Re Application Of: **TEN HOEVE et al.**

MAR 24 2005

Application No.	Filing Date	Examiner	Customer No.	Group Art Unit	Confirmation No.
10/048,040	01/24/2002	Teskin, F.M.	7590	1713	1130

Title: **METHOD OF PREPARING A POLYMER, METHOD OF PREPARING A COMPOUND, COMPOUNDS, POLYMERS, AND METHOD OF MANUFACTURING AN ELECTRONIC DEVICE**

Address to:

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

37 CFR 1.97(b)

- The Information Disclosure Statement submitted herewith is being filed within three months of the filing of a national application other than a continued prosecution application under 37 CFR 1.53(d); within three months of the date of entry of the national stage as set forth in 37 CFR 1.491 in an international application; before the mailing of a first Office Action on the merits, or before the mailing of a first Office Action after the filing of a request for continued examination under 37 CFR 1.114.

37 CFR 1.97(c)

- The Information Disclosure Statement submitted herewith is being filed after the period specified in 37 CFR 1.97(b), provided that the Information Disclosure Statement is filed before the mailing date of a Final Action under 37 CFR 1.113, a Notice of Allowance under 37 CFR 1.311, or an Action that otherwise closes prosecution in the application, and is accompanied by one of:

the statement specified in 37 CFR 1.97(e);

OR

the fee set forth in 37 CFR 1.17(p).

03/25/2005 FMETEK11 00000029 10048040

01 FC:1806

180.00 0P

TRANSMITTAL OF INFORMATION DISCLOSURE STATEMENT

(Under 37 CFR 1.97(b) or 1.97(c))

Docket No.

NL-010357

In Re Application: **TEN HOEVE et al.**
MAR 24 2005

Application No.	Patent & Trademark	Filing Date	Examiner	Customer No.	Group Art Unit	Confirmation No.
10/048,040		01/24/2002	Teskin, F.M.	7590	1713	1130

Title: **METHOD OF PREPARING A POLYMER, METHOD OF PREPARING A COMPOUND, COMPOUNDS, POLYMERS, AND METHOD OF MANUFACTURING AN ELECTRONIC DEVICE****Payment of Fee**

(Only complete if Applicant elects to pay the fee set forth in 37 CFR 1.17(p))

A check in the amount of **\$180.00** is attached.

The Director is hereby authorized to charge and credit Deposit Account No. **500999** as described below.

Charge the amount of

Credit any overpayment.

Charge any additional fee required.

Payment by credit card. Form PTO-2038 is attached.

WARNING: Information on this form may become public. Credit card information should not be included on this form. Provide credit card information and authorization on PTO-2038.**Certificate of Transmission by Facsimile***

I certify that this document and authorization to charge deposit account is being facsimile transmitted to the United States Patent and Trademark Office (Fax. No.

(Date)

Signature

Typed or Printed Name of Person Signing Certificate

Certificate of Mailing by First Class Mail

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to "Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450" [37 CFR 1.8(a)] on

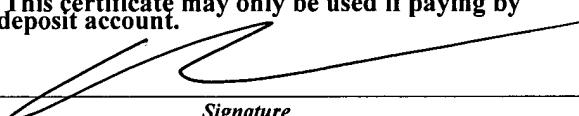
March 21, 2005

(Date)

Signature of Person Mailing Correspondence

Jennifer Shafer

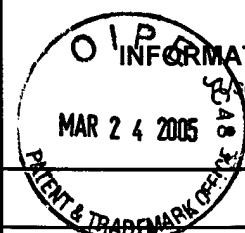
Typed or Printed Name of Person Mailing Certificate

***This certificate may only be used if paying by deposit account.**


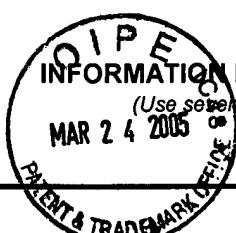
Signature

Dated: **March 21, 2005****Ronald A. D'Alessandro****Reg. No. 42,456****Hoffman, Warnick & D'Alessandro LLC****Three E-Comm Square****Albany, New York 12207****(518) 449-0044**

CC:



INFORMATION DISCLOSURE CITATION <small>(Use several sheets if necessary)</small> MAR 24 2005				ATTY DOCKET NO. NL-010357	APPLICATION NO. 10/048,040		
				APPLICANT(S) TEN HOEVE et al.			
				FILING DATE 01/24/2002	GROUP ART UNIT 1713		
U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
	4,766,198	08/1988	Harper et al.				
	4,900,782	02/1990	Han et al.				
	5,053,166	10/1991	Murase et al.				
U.S. PATENT APPLICATION PUBLICATIONS							
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
FOREIGN PATENT DOCUMENTS							
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
	PCT/EP 01/06049	09/2001	International Search Report			YES	NO
	WO 00/35987	06/2000	PCT				
	WO 01/18090 A1	03/2001	PCT				
OTHER DOCUMENTS <i>(Including Author, Title, Date, Pertinent Pages, Etc.)</i>							
		Van Breeman et al., "Highly Selective Route for Producing Unsymmetrically Substituted Monomers Toward Synthesis of Conjugated Polymers Derived from Poly(p-phenylene vinylene)", 1999, pp. 3106-3112.					
		Cheng et al., "New Precursors and Polymerization Route for the Preparation of High Molecular Mass Poly (3,4-Dialkoxy-2,5-Thienylenevinylene)s: Low Band Gap Conductive Polymers", 1995, pp. 1451-1452.					
EXAMINER				DATE CONSIDERED			
<small>*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.</small>							

**INFORMATION DISCLOSURE CITATION**

(Use several sheets if necessary)

MAR 24 2005

ATTY DOCKET NO.
NL-010357APPLICATION NO.
10/048,040

TEN HOEVE et al.

FILING

01/24/2002

GROUP ART

1713

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

U.S. PATENT APPLICATION PUBLICATIONS

*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION
							YES

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

"Polymerization of alpha, alpha' -Bis(dialkylsulfonio)-p-xylene Dihalides via p-Xylylene Intermediates: Evidence for a Nonradical Mechanism", 1988, pp. 7258-7259.

EXAMINER

DATE CONSIDERED

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.